Introduction

2020 International Conference on Pattern Recognition and Machine Learning (PRML 2020) will be held during July 16-18, 2020 in Sichuan University, Chengdu, China. PRML is an annual conference which aims to present the latest research and results of scholars and experts related to Pattern Recognition and Machine Learning. This conference provides opportunities for delegates from different areas to exchange new ideas, applications and experiences face to face, to establish business or research relations, and to find global partners for future collaboration.

Important Dates

Submission Deadline    Mar. 30, 2020
Notification             Apr. 20, 2020
Registration Deadline    May. 10, 2020
Conference Dates        Jul. 16-18, 2020

Contact Details

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Paper Publication

Publication in Conference Proceedings, which will be indexed by EI Compendex, Scopus, etc.

Some selected refereed papers describing the state-of-the-art topics will be considered for publication in the International Journal of Machine Learning and Computing (IJMLC) (ISSN: 2010-3700) as a Special Issue, which will be indexed by Scopus, EI (INSPEC, IET), Google Scholar, and etc.

Conference Topics

Pattern Recognition and Machine Learning

3D computer vision
Action and behavior recognition
Biometrics, face, gesture, body pose
Image retrieval
Low-level and physics-based vision
Machine learning architectures and formulations
Motion and tracking
Neural generative models, auto encoders, GANs
Transfer, low-shot, semi- and un-supervised learning
Video analysis and understanding
Vision + language, vision + other modalities
Optimization and learning methods

Submission Methods

Please submit your full paper/abstract to us via the:

Electronic Submission System or conference email box: prml@cbees.net

Listener Registration: Click Here

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